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First Named Inventor	Leonard Forbes	
Serial No.	10/775,424	
Filing Date	February 10, 2004	
Group Art Unit	2655	
Examiner Name	Unknown	
Confirmation No.	9726	
Attorney Docket No.	400.270US01	

GENERAL TRANSMITTAL FORM UNDER 37 CFR 1.8 (LARGE ENTITY)

Title: NROM FLASH MEMORY CELL WITH INTEGRATED DRAM

Mail Stop: AMENDMENT Commissioner for Patents P. O. Box 1450

Alexandria, VA 22313-1450

Enclosure		

The following documents are enclosed:

- X Information Disclosure Statement (1 pg.); Form 1449 (7 pgs.); 59 copies of cited references; U.S. reference(s) not included pursuant to 37 C.F.R. 1.98 (c)(2)(i);
- X An itemized return-receipt postcard

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Please charge any additional fees or credit any overpayments to Deposit Account No. 501373.

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Name	Rhonda L. Foley	Signat	ure	nda L	tolu		
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(LARGE ENTITY TRANSMITTAL UNDER 37 CFR § 1.8)

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NROM FLASH MEMORY CELL WITH INTEGRATED DRAM

INFORMATION DISCLOSURE STATEMENT

Mail Stop: AMENDMENT

Commissioner for Patents P.O. Box 1450

Title:

Alexandria, VA 22313-1450

In compliance with 37 C.F.R. §§ 1.56 and 1.97, et seq., the enclosed materials are brought to the attention of the Examiner for consideration in connection with the above-identified Application. Pursuant to 37 C.F.R. 1.98 (a)(2)(i), as this application was filed after June 30, 2003, Applicant has not included copies of U.S. Patents or U.S. Patent Applications. Applicant respectfully requests that this Information Disclosure Statement be entered and the references listed on the attached Form 1449 be considered by the Examiner and made of record. Pursuant to MPEP §609, Applicant further requests that the Examiner initial next to each reference on the Form 1449 to indicate that the listed references have been considered. Applicant further requests that a copy of the initialed Form 1449 be returned with the next official communication.

As an Office Action has not yet issued in this application, Applicant believes that no fees are due. However, the Commissioner for Patents is hereby authorized to charge any additional fees to Deposit Account No. 501373.

If the Examiner has any questions or concerns regarding this application, please contact the undersigned at (612) 312-2211.

Respectfully submitted,

Date:

Kenneth W. Bolvin Reg. No. 34,125

Attorneys for Applicant Leffert Jay & Polglaze P.O. Box 581009 Minneapolis, MN 55458-1009 T 612 312-2200 F 612 312-2250



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INFORMATION DISCLOSURE STATEMENT FORM PTO-1449

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